

Weekly meeting

2019/11/15

Working status

1. Fabrication project : 2nd niobium deposition onto the 1st niobium layer (with Dr. Jeon, Freerik)

- We are using two wafers differing in width of SiO2 layer
- SiO2 patterning is over (11/14)
- Second Nb patterning is scheduled at 11/19 in KRISS



Nb 2layer Fabrication process for contact test







